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FORM PTO-1449 (Modified) SP 0 7 2001 2	ATTY. DOCKET NO. YOR920000692US1	SERIAL NO. 09/769,170,	
LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DEMANDS DISCLOSURE STATEMENT	APPLICANT: J.O. Chu et al	. E800 to	Ñ
(Use several sheets if necessary)	FILING DATE: January 25, 2001	GROUP: 7 7 7 7 7 7 7 7 7 7 7 7 7 7 7 7 7 7 7	<u>۔</u>
REFERENCE DESIGNATION U.S. PATI	ENT DOCUMENTS	3	

REFERENCE DESIGNATION			U.S. PATENT DOCUMENTS				<i></i>	
EXAMINE R INITIALS		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE (IF APPRO.)	
80)	AA	5,674,758	10/7/1997	McCarthy	437	21	06/06/1995	
	AB	5,994,207	11/30/1999	Henley et al.	438	515	02/19/1998	
	AC	5,528,397	06/18/1996	Zavracky et al.	359	59	07/28/1994	
	AD	5,399,231	03/21/1995	McCarthy	156	630	10/18/1993	
	AE	5,877,034	03/02/1999	Ramm et al.	438	15	09/22/1995	
	AF	6,033,974	03/07/2000	Henley et al.	438	526	08/10/1999	
	AG	5,876,497	03/02/1999	Atoji	117	85	12/09/1996	
$\overline{}$	AH	5,856,229	01/05/1999	Sakaguchi et al.	438	406	05/27/1997	
	ΑI	5,882,987	03/16/1999	Srikrishnan	438	458	08/26/1997	
	AJ	5,710,057	01/20/1998	Kenney	437	62	07/12/1996	
	AK	5,374,564	12/20/1994	Bruel	437	24	09/15/1992	
EÜ	AL	5,906,951	05/25/1999	Chu et al.	438	751	04/30/1997	

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSI YES	NO NO
En	АМ	96,264,386	6/20/1997	Japan				
p.								

OTHER ART (Including Author, Title, Date, Pertinent Pages, etc.)

En	AN	K. Sakaguchi et al., "SOI Wafers Epitaxial Technology", Solid State Technology, June 2000, pp.88-92
	AO	

EXAMINER

SA

DATE CONSIDERED /2-10-02

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.